Abstract

The inventive photoreactive device has a semiconductor and an oxidation reduction material. The semiconductor has a conduction band with a potential and being capable of producing electrons under the irradiation of light on the semiconductor. The oxidation reduction material has a redox potential being positive compared with the potential of the conduction band. The semiconductor supplies electrons into the oxidation reduction material to reduce it under the irradiation of light for storing the electrons. The stored electrons are discharged from the oxidation reduction material into a metal material to prevent the corrosion of the metal material.